

1 1. Apparatus for automatically measuring the surface properties of optical
2 elements, said apparatus comprising:
3 a support for an element having at least one test surface to be measured;
4 means for generating an output beam having a predetermined wavefront
5 profile;
6 means for controllably positioning said output beam with respect to said
7 support so that said predetermined wavefront profile thereof impinges on said element
8 from a predetermined direction and then is reflected to travel opposite said
9 predetermined direction as a distorted wavefront containing distortions that vary in
10 accordance with the topography of said test surface and the position of said output
11 beam; and
12 means for sampling said distorted wavefront profile at predetermined locations
13 thereover as said output beam is moved relative to said test surface and determining
14 the local deformation of said wavefront everywhere corresponding to a sampled
15 location and the position of said output beam with respect to said test surface.

1 2. The apparatus of claim 1 further including analytical means for representing
2 the topography of said test surface with a mathematical approximation comprising a
3 series of coefficients and variables; calculating the value of said coefficients based on
4 the local deformation of said wavefront at at least one position of said source with
5 respect to said test surface.

1 3. The apparatus of claim 2 wherein said analytical means includes means for
2 performing an optimization analysis using the values of said coefficients calculated for
3 each position of said source and test surface to arrive at a final value for said
4 coefficients that are used for said mathematical approximation to represent the shape
5 of said surface to a predetermined accuracy.

4. The apparatus of claim 1 wherein said predetermined wavefront comprises a
plane wavefront.

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5. The apparatus of claim 1 wherein said predetermined wavefront comprises a nominally spherical wavefront.

6. The apparatus of claim 1 wherein said means for generating said output beam comprises a light source and collimating optics.

7. The apparatus of claim 6 further including a well-corrected objective lens.

8. The apparatus of claim 1 further including a positive lens located in a fixed position with respect to said support and along said predetermined direction to facilitate the measurement of parts having long radii of curvature.

9. The apparatus of claim 4 further including a reflective means positioned with respect to said support to facilitate the measurement of transmitted wavefront errors in optical bandpass components including filters and windows.

10. The apparatus of claim 9 further including a relay section.

11. The apparatus of claim 4 further including a beam expansion section.

12. The apparatus of claim 1 wherein said means for sampling said distorted wavefront comprises a two-dimensional lens array and a two-dimensional photodetector array having discrete sensing elements.

1 13. The apparatus of claim 12 wherein said two-dimensional lens array
2 comprises a pair of crossed lenticular screens with index mismatching material
3 between them.

1 14. The apparatus of claim 12 wherein said means for generating said output
2 beam comprises a microscope objective lens and further including a telescopic section
3 between said microscope objective lens and said two-dimensional lens array to image
4 said two-dimensional photodetector array into the pupil of said microscope objective
5 lens.

1 15. Apparatus for automatically measuring the properties of surfaces that are at
2 least partially specularly reflective, said apparatus comprising:
3 a support for an element having at least one test surface to be measured;
4 a source having an output with a predetermined wavefront profile;
5 means for controllably moving said source and said support relative to one
6 another so that a test surface in said support continuously reflects said output from said
7 source back towards said source while distorting said wavefront profile thereof in
8 accordance with the topography of said test surface and the relative position of said
9 source with respect to said test surface; and
10 means for sampling said distorted wavefront profile at predetermined locations
11 thereover as said source is moved relative to said test surface and determining the local
12 deformation of said wavefront everywhere corresponding to a sampled location and the
13 position of said source with respect to said test surface.

1 16. The apparatus of claim 15 further including analytical means for
2 representing the topography of said test surface with a mathematical approximation
3 comprising a series of coefficients and variables; calculating the value of said
4 coefficients based on the local deformation of said wavefront at at least one position of
5 said source with respect to said test surface.

1 17. The apparatus of claim 15 wherein said analytical means includes means
2 for performing an optimization analysis using the values of said coefficients calculated
3 for each position of said source and test surface to arrive at a final value for said

4 coefficients that are used for said mathematical approximation to represent the shape
5 of said surface to a predetermined accuracy.

1 18. The apparatus of claim 1 wherein said means for sampling said distorted
2 wavefront profile comprises a two-dimensional lenslet array having a focal plane and a
3 one-dimensional photodetector array arranged to scan across said focal plane.

1 19. The apparatus of claim 1 wherein said means for generating an output
2 beam comprises one of a pulsed light source or strobe.

1 20. A method for automatically measuring the surface properties of optical
2 elements, said method comprising the steps of:
3 supporting an element having at least one test surface to be measured;
4 generating an output beam having a predetermined wavefront profile;
5 controllably positioning said output beam with respect to said support so that
6 said predetermined wavefront profile thereof impinges on said element from a
7 predetermined direction and then is reflected to travel opposite said predetermined
8 direction as a distorted wavefront containing distortions that vary in accordance with
9 the topography of said test surface and the position of said output beam; and
10 sampling said distorted wavefront profile at predetermined locations thereover
11 as said output beam is moved relative to said test surface and determining the local
12 deformation of said wavefront everywhere corresponding to a sampled location and the
13 position of said output beam with respect to said test surface.

1 21. The method of claim 20 further including the step of analytically
2 representing the topography of said test surface with a mathematical approximation
3 comprising a series of coefficients and variables and calculating the value of said
4 coefficients based on the local deformation of said wavefront at at least one position of
5 said source with respect to said test surface.

*add
and*